

INFORMATION DISCLOSURE STATEMENT

Applicant : Hirayama et al.
App. No : 10/590,046
Filed : June 15, 2007
For : BASE MATERIAL FOR PATTERN-
FORMING MATERIAL, POSITIVE
RESIST COMPOSITION AND METHOD
OF RESIST PATTERN FORMATION
Examiner : Johnson, Connie P.
Art Unit : 1795
Conf No. : 5635

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:


Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing 31 references, of which 26 are submitted.

This Information Disclosure Statement is being filed before the mailing date of a final action and before the mailing of a Notice of Allowance. This Statement is accompanied by the fees set forth in 37 C.F.R. § 1.17(p). The Commissioner is hereby authorized to charge any additional fees which may be required or to credit any overpayment to Account No. 11-1410.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: 5/12/10

By: 
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